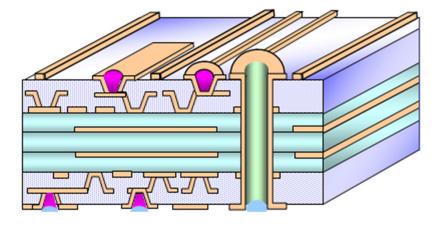
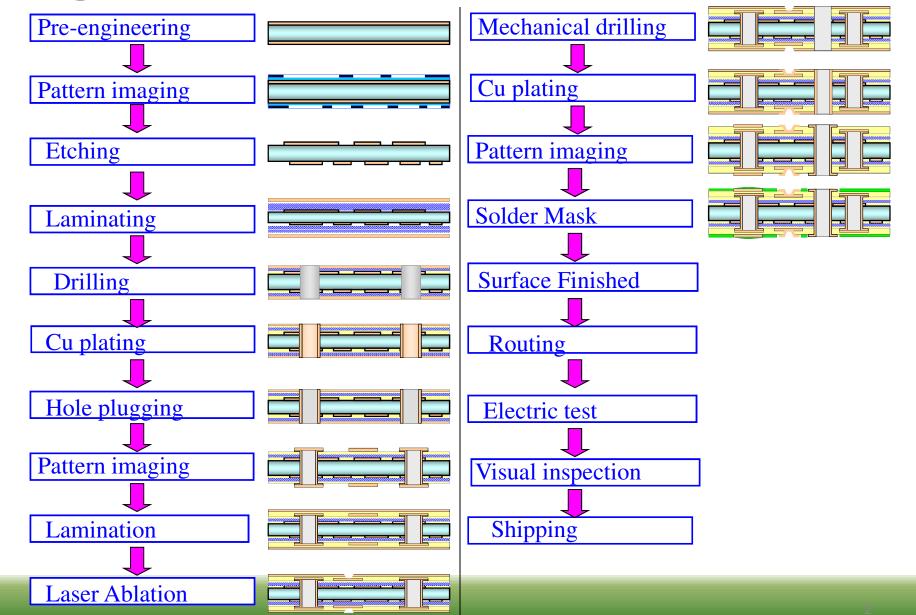


#### Start

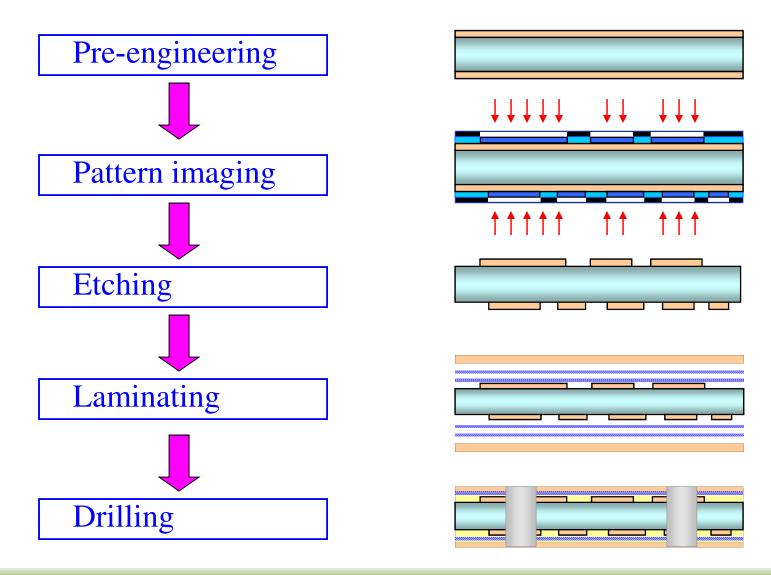


# HDI Manufacturing Proces Flow

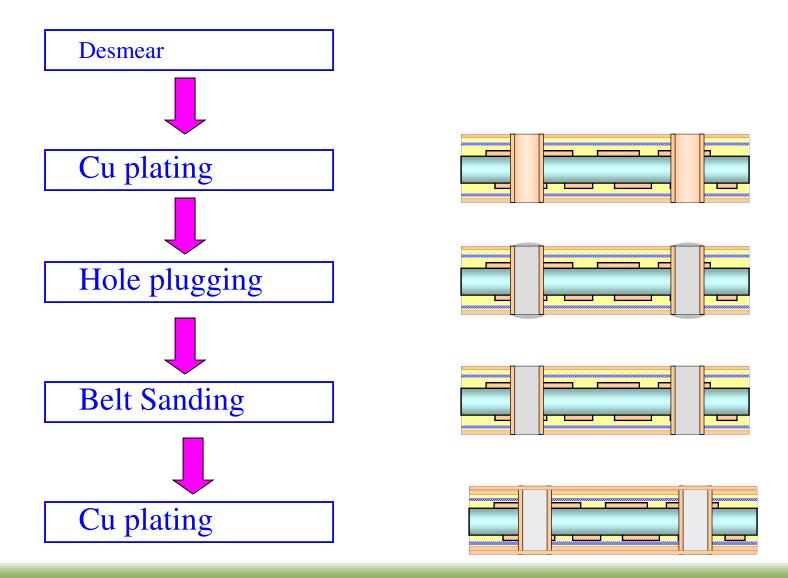
# **HPCB**



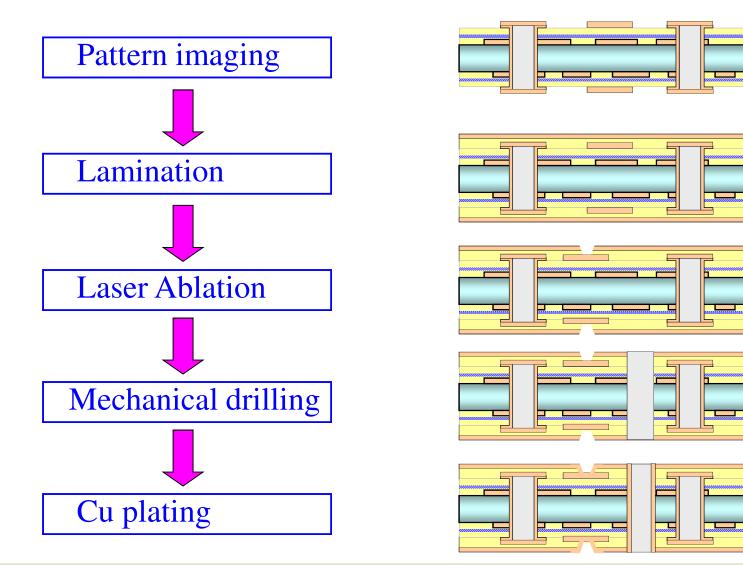




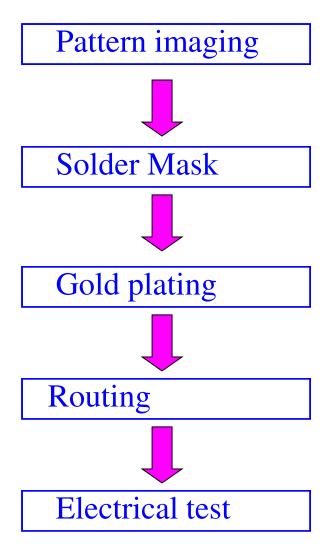


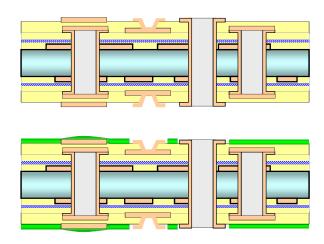














Visual inspection



Hole counter



**Shipping** 



### \* Raw material (Thin Core, Copper, Prepreg.....)

```
Raw Material : FR-4 (Difuntional, Tetrafuntional)
```

Supplier : EMC ,Nan-Ya

Sheet size : 36"\*48", 40"\*48", 42"\*48

Core Thickness: 0.003", 0.004", 0.005", 0.006"

0.008", 0.010", 0.012", 0.015"

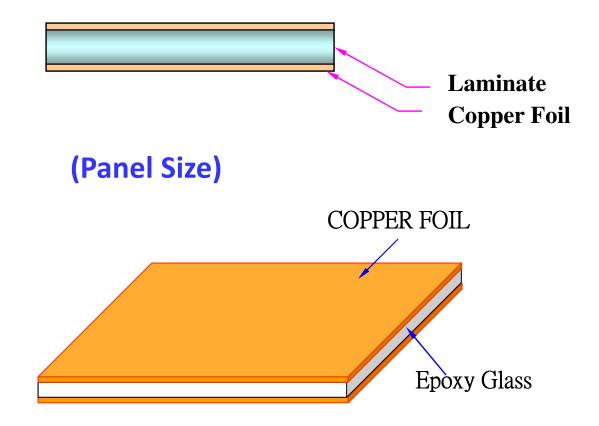
0.021", 0.031", 0.039", 0.047"

Copper Foil : 1/3 oz,1/2 oz,1.0 oz,2 oz

Prepreg type : 1080,2113,2116,1506,7628,7630

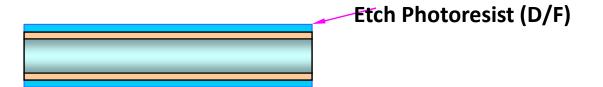


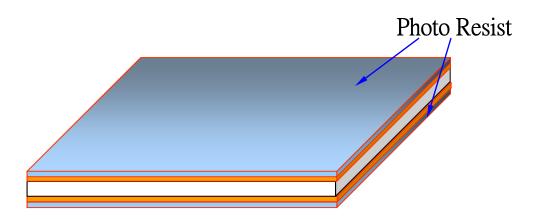
### 1. Innerlayer (THIN CORE)





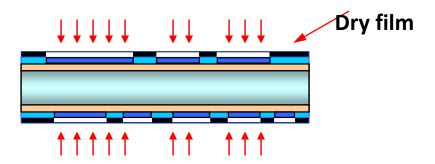
## 2. Dry Film Resist Coat

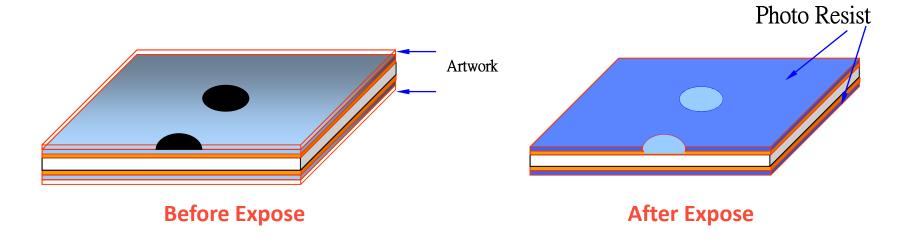






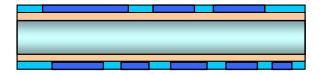
#### 3. Inner Artwork Expose

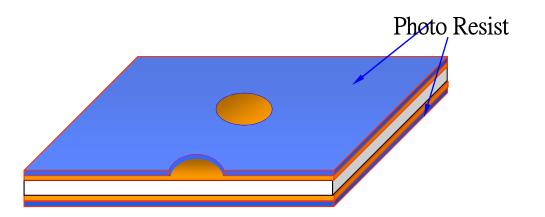






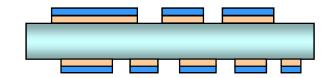
## 4. Inner layer immage Develop

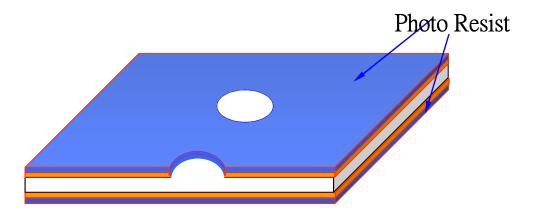






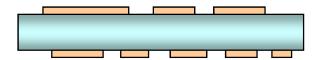
## 5. Inner Layer Etch

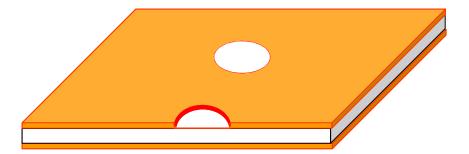






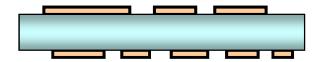
## 6. Inner Layer Strip Resist

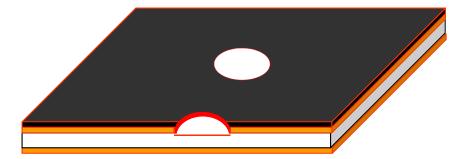






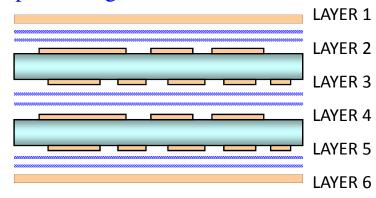
## 7. Oxide Coating

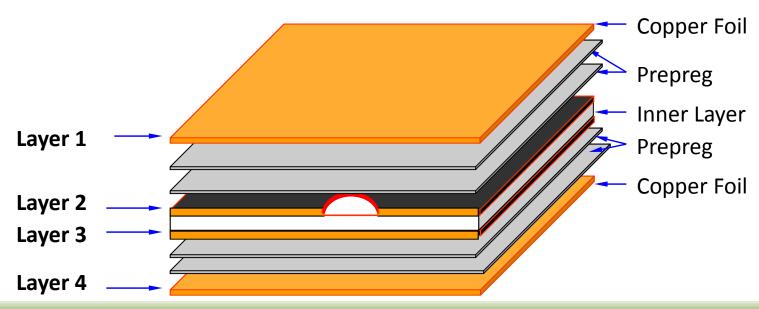






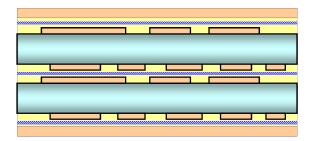
### 8. Lay-up Building

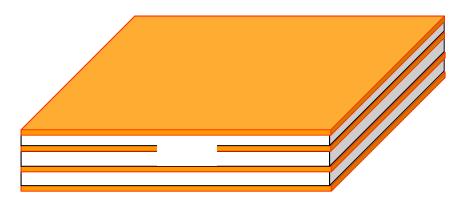






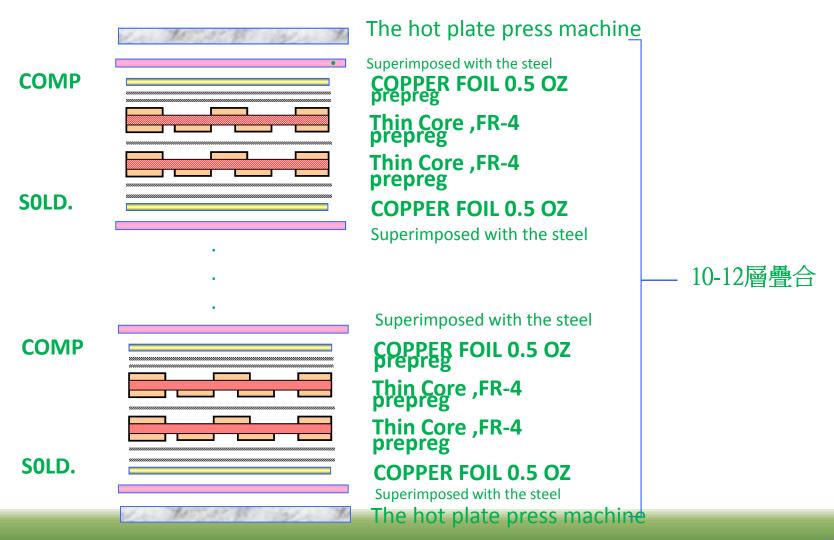
#### 9. Lamination





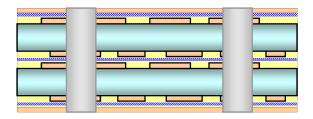


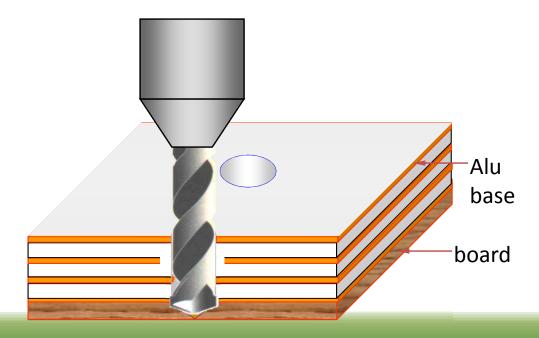
#### Typical of the multilayer structure of stacked plates and laminated





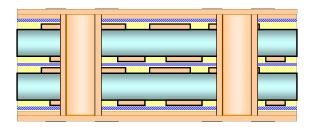
# 10. NC Drilling

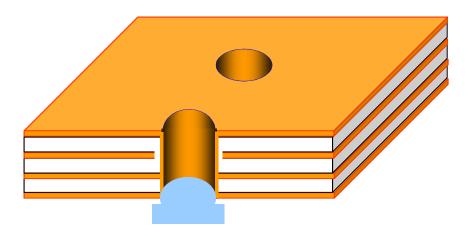






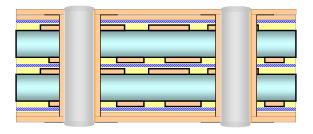
# 11. Desmear & Copper Deposition



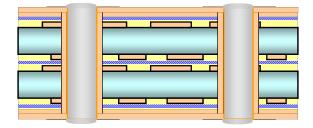




# 12. Hole Plugging

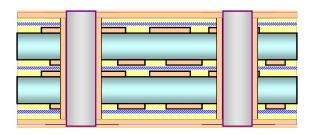


## 13. Belt Sanding

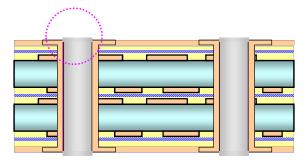




# 14. Copper Reduction → Option

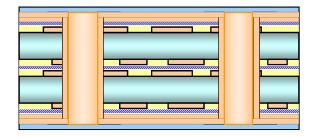


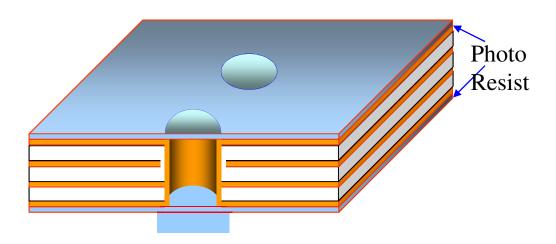
## 15. Belt Sanding → Option





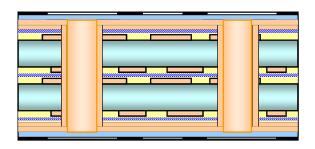
## 16. Dry Film Lamination (Outer layer)

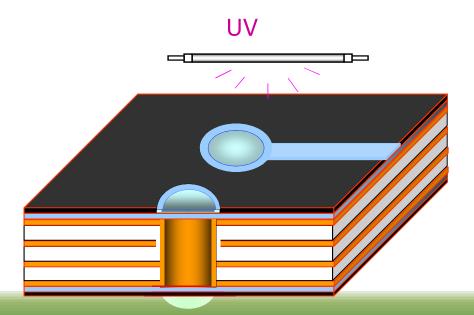






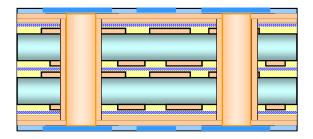
# 17. Outerlayer Expose

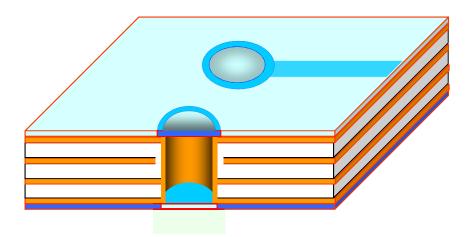






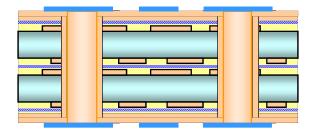
# 18. After Exposed

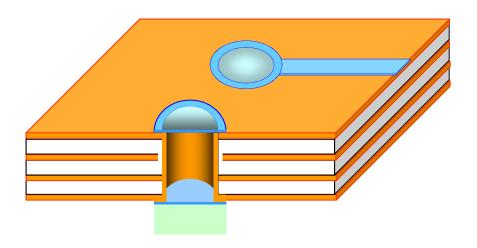






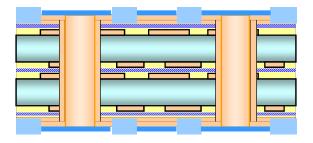
# 19. Outerlayer Develop

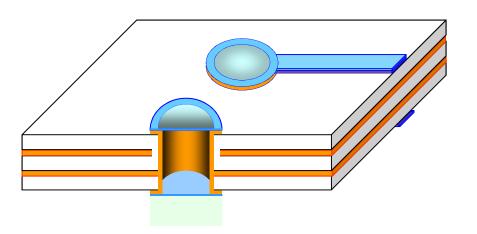






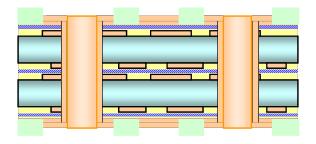
#### 20. Etch

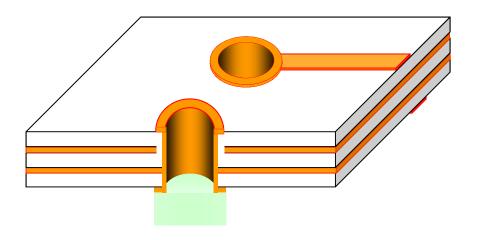






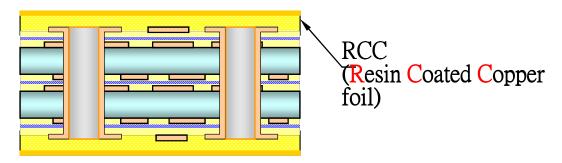
# 20. Strip Resist

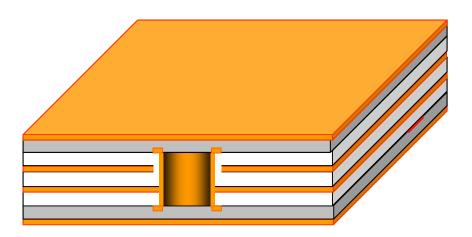






## 21. Build-up Layer Lamination





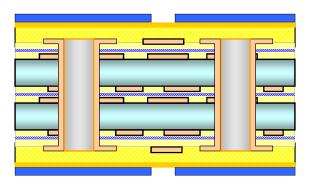


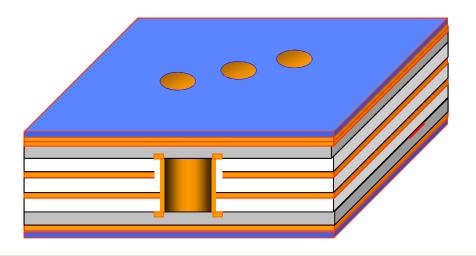
#### 22. Conformal Mask

Artwork Before Exposure Artwork After Exposure



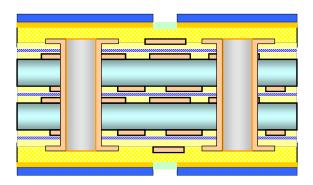
#### 23.Conformal Mask

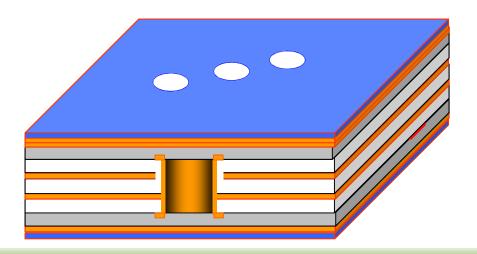






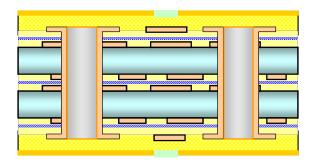
## 24. Conformal Mask (for Etching)

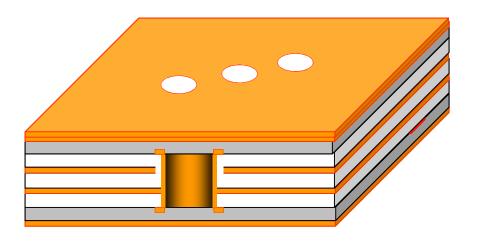






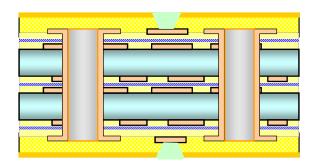
#### 25. Conformal Mask

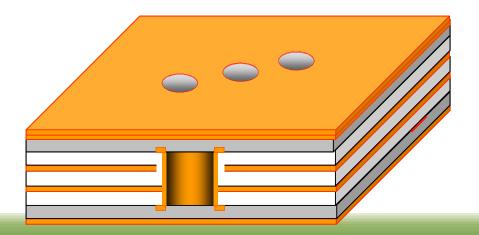






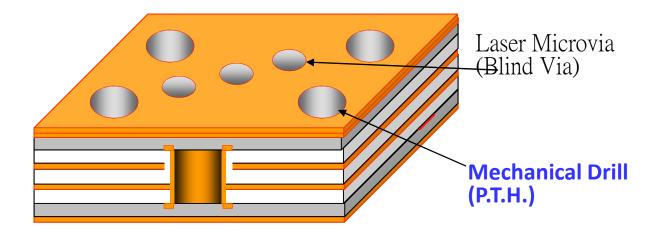
# 26. Laser Ablation and NC Drilling





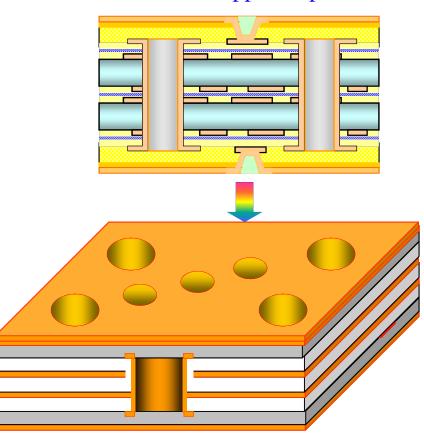


#### 27. Mechanical Drill



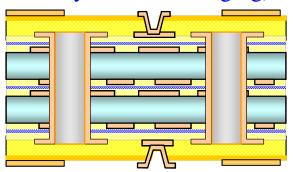


# 28. Desmear & Copper Deposition

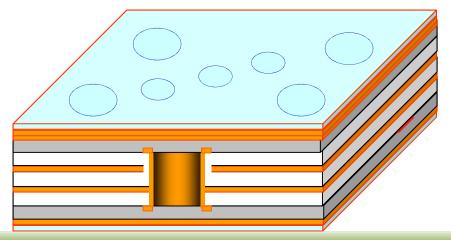




## 29. Outerlayer Pattern imaging)

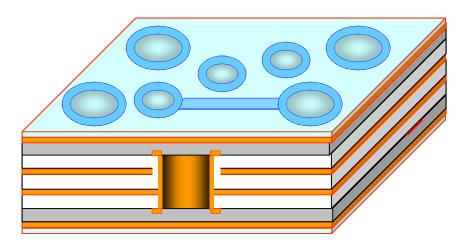


# **Dry Film Lamination)**

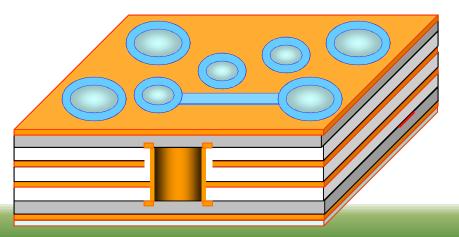




## **Outerlayer Exposure**

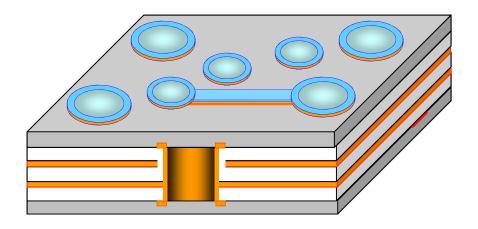


# **Dry Film Developing**

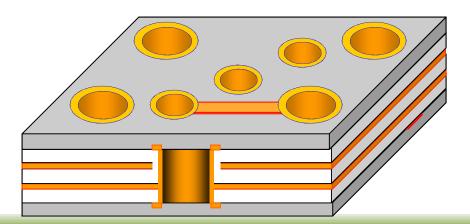




# **Etching**

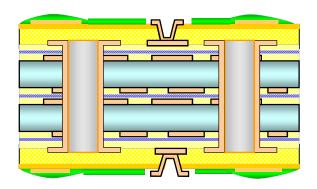


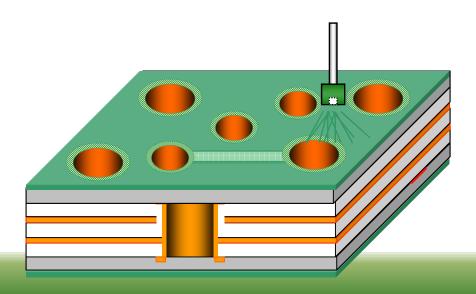
# **Dry Film Stripping**





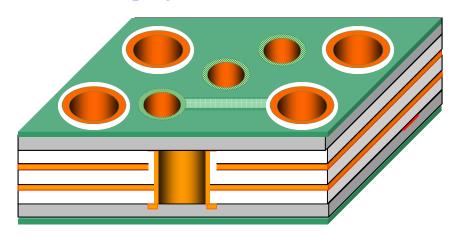
### 30. Solder Mask Process



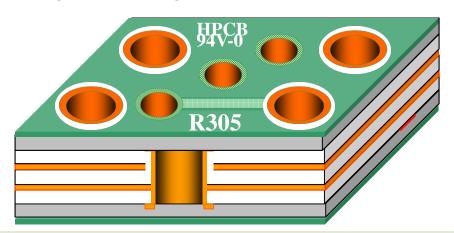




### 31. S/M Developing

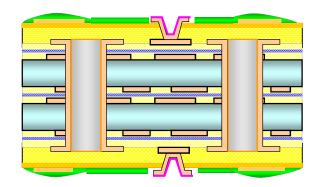


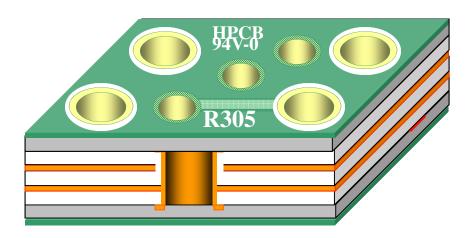
## 32. Legend Printing





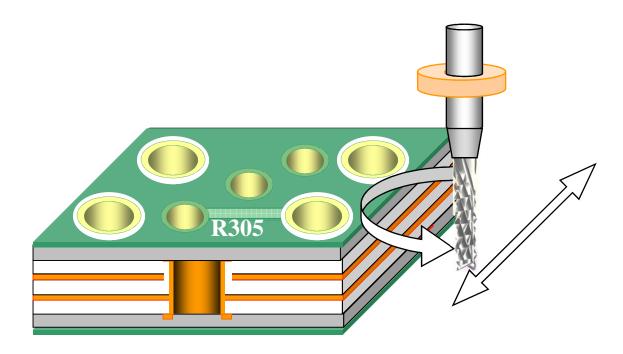
33. Electroless Ni/Au , HAL\_lead free and Etc.



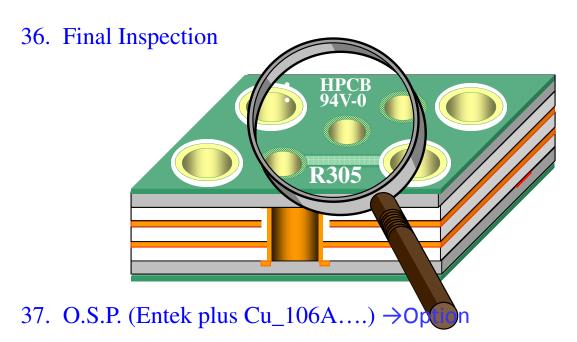


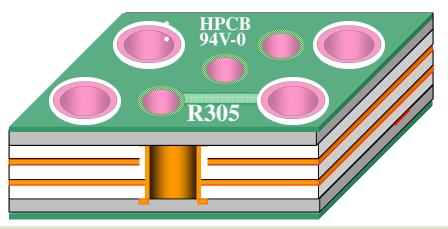


## 34. Outline Profile and Electrical Testing











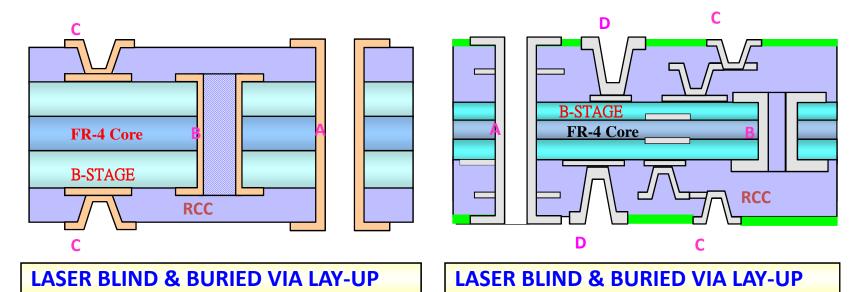
#### **BURIED VIA AND LASER BLIND VIA OPTION**

**A = THROUGH VIA HOLE** 

**B = BURIED VIA HOLE** 

**C** = One Level Laser Blind Via

**D** = Two Level Laser Via





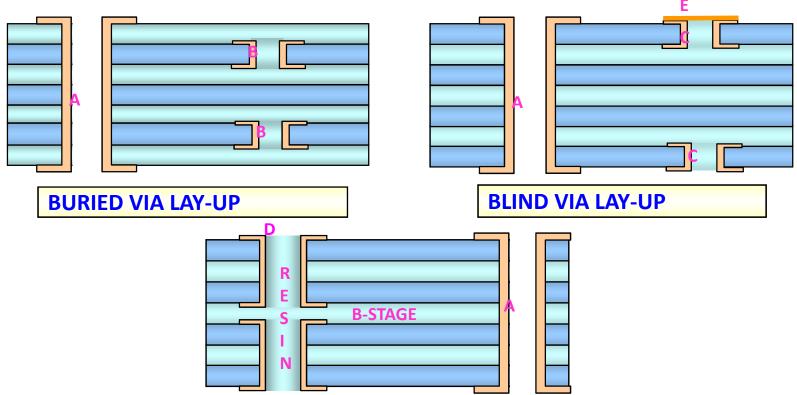
#### **BLIND AND BURIED VIA OPTION**

**A = THROUGH VIA HOLE** 

**B = BURIED VIA HOLE** 

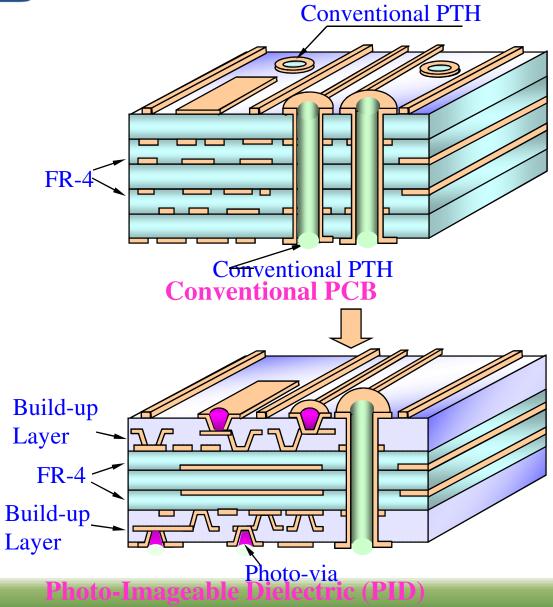
**C = BLIND VIA HOLE** 

**D** = **BLIND HOLE MLB VIA** 

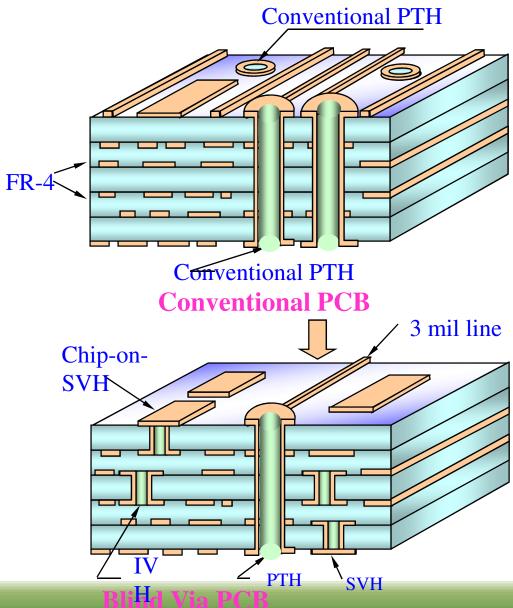


**BLIND VIA SEQUENTIAL LAY-UP** 









## End

